## Freeform Search

**	US Pre-Grant Publication Full-Text Database					
	US Patents Full-Text Database					
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Database:						
	JPO Abstracts Database Derwent World Patents Index					
	IBM Technical Disclosure Bulletins					
	5532094.pn.					
Term:						
Display:	10 Documents in Display Format: - Starting with Number 1					
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Generate: ○ Hit List ⊙ Hit Count ○ Side by Side ○ Image						
8						
	Search Clear Interrupt					
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## DATE: Thursday, February 05, 2004 Printable Copy Create Case

Set Name side by side	Query	<u>Hit</u> Count	Set Name result set
DB=	=PGPB,USPT; PLUR=YES; OP=ADJ		
<u>L24</u>	L22 and polish	0	<u>L24</u>
<u>L23</u>	L22 and polishing	0	<u>L23</u>
<u>L22</u>	5532094.pn.	1	<u>L22</u>
<u>L21</u>	5232094.pn.	1	<u>L21</u>
<u>L20</u>	112 and (solution or slurry) near10(halogen or polyhalide)	63	<u>L20</u>
<u>L19</u>	112 and (halogen or polyhalide) near3 ion	84	<u>L19</u>
<u>L18</u>	L17	0	<u>L18</u>
<u>L17</u>	112 and (hologen or polyhalide) near3 ion	0	<u>L17</u>
<u>L16</u>	112 and (halogen or polyhalide)	1294	<u>L16</u>
DB=	USPT,PGPB,JPAB,EPAB,DWPI,TDBD; PLUR=YES; OP=ADJ		
<u>L15</u>	L14 not L13	111	<u>L15</u>
<u>L14</u>	L12 and L10	123	<u>L14</u>
L13	L12 and L11	12	<u>L13</u>
<u>L12</u>	(51/307  51/308  51/309 OR 106/3 OR 252/79.1  252/79.2  252/79.3  252/79.4  252/79.5 OR 438/692  438/693 OR 216/\$)! CCLS.	25226	<u>L12</u>

<u>L11</u>	L10 and edta	166	<u>L11</u>
<u>L10</u>	(iodine or bromine or fluorine or sulfuric or hydrochloric or carbonic or iodide) and ((polymer near2 particle or abrasive) same (polystyrene or polytetrafluoroethylene or polyamide or silver or porous silica or porous silicon))	2231	<u>L10</u>
<u>L9</u>	L6 and (surfactant or passivating or triazole or benzotriazole or chelating or edta or ethylenediaminetretaacetic or polymer)	24	<u>L9</u>
<u>L8</u>	polishing near20 (solution near5 (iodine or bromine or fluorine or sulfuric or hydrochloric or carbonic or iodide)) and (polystyrene or polytetrafluoroethylene or polyamide or silver or porous silica or porous silicon)	67	<u>L8</u>
DB=	=USPT,PGPB; PLUR=YES; OP=ADJ		
<u>L7</u>	polishing near20 (solution near5 (iodine or bromine or fluorine or sulfuric or hydrochloric or carbonic or iodide)) and (polystyrene or polytetrafluoroethylene or polyamide or silver or porous silica or porous silican)	59	<u>L7</u>
<u>L6</u>	L5 not L4	`46	<u>L6</u>
<u>L5</u>	(51/307   51/308   51/309 OR 106/3 OR 252/79.1   252/79.2   252/79.3   252/79.4   252/79.5 OR 438/692   438/693 OR 216/\$)!. CCLS. and polishing near 20 (solution near 5 (iodine or bromine or fluorine or sulfuric or hydrochloric or carbonic or iodide))	55	<u>L5</u>
<u>L4</u>	(51/307   51/308   51/309 OR 106/3 OR 252/79.1   252/79.2   252/79.3   252/79.4   252/79.5 OR 438/692   438/693 OR 216/\$)!. CCLS. and polishing near 20 (solution near 5 (iodine or bromine or fluorine or sulfuric or hydrochloric or carbonic or iodide)).clm.	, 9	<u>L4</u>
<u>L3</u>	L2 and (polytetrafluoroethylene or polyamide or silver or porous silica or porous silicon) near10 (particle or abrasive)	29	<u>L3</u>
<u>L2</u>	(51/307   51/308   51/309 OR 106/3 OR 252/79.1   252/79.2   252/79.3   252/79.4   252/79.5 OR 438/692   438/693 OR 216/\$)!. CCLS. and solution near5 (iodine or bromine or fluorine or sulfuric or hydrochloric or carbonic or iodide)	1397	<u>L2</u>
<u>L1</u>	(51/307   51/308   51/309 OR 106/3 OR 252/79.1   252/79.2   252/79.3   252/79.4   252/79.5 OR 438/692   438/693 OR 216/\$)!. CCLS. and solution near5 (iodine or bromine or fluorinbe or sulfuric or hydrochloric or carbonic or iodide)	1330	<u>L1</u>

## END OF SEARCH HISTORY